

Glimpse

The front loading chamber of the Univex 350 provides for easy access to the deposition sources and makes it easy to load and unload substrates.

You can choose from either a turbomolecular or cryopump vacuum pumping option.

The Univex 350 can also be installed in a clean room wall if desired.



- **the universal lab coater**
- box coater with 350mm wide vacuum chamber
- modular rack system
- high vacuum pump connection at the chamber back side
- PLC controlled system operation
- **Advantages**
- flexible experimental system
- compact design, small footprint
- customized system configuration
- integration of any process components
- easy operation via colored graphic touch screen
- modular extendable
- **Typical applications**
- manually controlled or automated coating batches in research, development and pilot production
- thermal evaporation, electron beam
- evaporation and RF/DC sputtering as single or combined processes
- max. substrate diameter: 320mm